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Information Disclosure Statement by Applicant						Applicant: Marie D'Angelo, et al.			
(Use several sheets if necessary)						Filed: January 5, 2005		Group: (to be assigned)	
<b>U.S. Patent Documents</b>									
Init.		Document No.	Date	Name	Class	Subclass	Filing Date		
TC/	A	US2004/0132242	7/8/04	D'Angelo et al.					
	B	3,998,662	12/21/76	Anthony et al.					
	C	4,735,921	4/5/88	Soukiassian					
	D	4,900,710	2/13/90	Soukiassian et al.					
	E	6,274,234	8/14/01	Dujardin et al.					
	F	6,667,102	12/23/03	Amy et al.					
<b>Foreign Documents</b>									
Init.		Document No.	Date	Country	Class	Subclass	Translation		
TC/	G	2 757 183	12/16/96	France			Yes	No	
TC/	H	2 786 794	12/2/98	France (w/English Abstract)					X
<b>Other Documents (Including Author, Title, Date, Pertinent Pages, etc.)</b>									
TC/	I	Crommie, M.F. et al., "Waves on a Metal Surface and Quantum Corrals", <i>Surface Review and Letters</i> , Vol. 2, No. 1, pages 127-137 (1995)							
	J	Franciosi, A. et al., "Electronic promoters and semiconductor oxidation: Alkali metals on Si(111) surfaces", <i>Physical Review B</i> , Vol. 35, No. 2, pages 910-913 (1987)							
	K	Gentle, T. M., "CH <sub>3</sub> Cl Adsorption on a Si(100)2 X 1 Surface Modified by Alkali Metal Overlayer Studied by Soft X-Ray Photoemission Using Synchrotron Radiation", <i>Surface Science Letters</i> 202, pages 568-576 (1988)							
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	P	Soukiassian, P., et al., "Catalytic Nitridation of a III-V Semiconductor Using Alkali Metal", <i>Europhysics Letters</i> 12, pages 87-92 (1990)							
	Q	Soukiassian, P., et al., "Catalytic Oxidation of Semiconductors by Alkali Metals", <i>Physica Scripta</i> , Vol. 35, pages 757-760 (1987)							
	R	Soukiassian, P., et al., "Electronic Promotion of Silicon Nitridation by Alkali Metals", <i>Physical Review Letters</i> , Vol. 59, No. 13, pages 1488-1491 (1987)							
Examiner					Date Considered				
/Tsz Chiu/ (10/01/2007)					10/01/2007				
Examiner: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include a copy of this form with the next communication to applicant.									

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